

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

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Title of Invention

GENERATING MASK PATTERNS FOR ALTERNATING
PHASE-SHIFT MASK LITHOGRAPHY

Application Number : 12 604573

Confirmation Number:

First Named Applicant: Lars Liebmann

Attorney Docket Number: FIS920020113

Art Unit: 2825

Examiner: Dinyan

Search string: (5807649 or 6258493 or 6338922 or 20020071997 or 20020045136 or
20020083410 or 20020081500 or 20020094492 or 20010028985).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
<u>H70</u>	1	5807649	1998-09-15	Liebmann et al.	<u> </u>		
<u>1</u>	2	6258493	2001-07-10	Wang et al.	<u> </u>		
<u>3</u>	3	6338922	2002-01-15	Liebmann et al.	<u> </u>		

US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
<u>H70</u>	1	20020071997	2002-06-13	Ahrens et al.	<u> </u>		
<u>1</u>	2	20020045136	2002-04-18	Fritze et al.	<u> </u>		
<u>3</u>	3	20020083410	2002-06-27	Wu et al.	<u> </u>		
<u>4</u>	4	20020081500	2002-06-27	Cobb et al.	<u> </u>		
<u>5</u>	5	20020094492	2002-06-18	Randall et al.	<u> </u>		
<u>6</u>	6	20010028985	2001-10-11	Wang et al.	<u> </u>		

Signature

Examiner Name

Date

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07/29/05